Refine Search

Search Results -

Terms	Documents
semiconductor and (((trench or groove) near3 fill) same liquid)	1

Database:
US Pre-Grant Publication Full-Text Database
US Patents Full-Text Database
US OCR Full-Text Database
EPO Abstracts Database
JPO Abstracts Database
Derwent World Patents Index
IBM Technical Disclosure Bulletins

Search: L22

Refine Search

Recall Text ⬍   Clear   Interrupt

Search History

DATE: Tuesday, July 19, 2005   Printable Copy   Create Case

Set Name side by side	Query	Hit Count	Set Name result set
	DB=TDBD; PLUR=YES; OP=ADJ		
L22	semiconductor and (((trench or groove) near3 fill) same liquid)	1	L22
	DB=DWPI; PLUR=YES; OP=ADJ		
L21	semiconductor and (((trench or groove) near3 fill) same liquid)	17	L21
	DB=JPAB; PLUR=YES; OP=ADJ		
L20	semiconductor and (((trench or groove) near3 fill) same liquid)	22	L20
	DB=EPAB; PLUR=YES; OP=ADJ		
L19	semiconductor and (((trench or groove) near3 fill) same liquid)	0	L19
	DB=USPT; PLUR=YES; OP=ADJ		
L18	semiconductor and (((trench or groove) near3 fill) same liquid)	150	L18
	DB=PGPB; PLUR=YES; OP=ADJ		
L17	semiconductor and (((trench or groove) near3 fill) same liquid)	95	L17
L16	20040266153	1	L16
L15	20040209484	1	L15
L14	20030129826	1	L14
L13	20030032281	1	L13

L12	200300322281		0	L12
L11	20020018849		1	L11
L10	20020000195		1	L10
L9	20010041250		1	L9
L8	2001/0041250		0	L8

DB=DWPI; PLUR=YES; OP=ADJ

| L7 | 2001/0041250 | | 0 | L7 |

DB=JPAB; PLUR=YES; OP=ADJ

| L6 | (self aligned) and silicide and (SiGe or (silicon adj germanium)) and metal and ((thermal or heat$) near3 anneal$) | 0 | L6 |

DB=EPAB; PLUR=YES; OP=ADJ

| L5 | (self aligned) and silicide and (SiGe or (silicon adj germanium)) and metal and ((thermal or heat$) near3 anneal$) | 0 | L5 |

DB=USPT; PLUR=YES; OP=ADJ

| L4 | (self aligned) and silicide and (SiGe or (silicon adj germanium)) and metal and ((thermal or heat$) near3 anneal$) | 322 | L4 |

DB=PGPB; PLUR=YES; OP=ADJ

| L3 | (self aligned) and silicide and (SiGe or (silicon adj germanium)) and metal and ((thermal or heat$) near3 anneal$) | 246 | L3 |

DB=TDBD; PLUR=YES; OP=ADJ

| L2 | (self aligned) and silicide and (SiGe or (silicon adj germanium)) and metal and ((thermal or heat$) near3 anneal$) | 1 | L2 |

DB=DWPI; PLUR=YES; OP=ADJ

| L1 | (self aligned) and silicide and (SiGe or (silicon adj germanium)) and metal and ((thermal or heat$) near3 anneal$) | 3 | L1 |

END OF SEARCH HISTORY

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	0	(isolation adj trench) and (liquid adj deposition) and (solid adj deposition)".clm"	USPAT	ADJ	ON	2005/07/19 14:17
L2	1419	(438/424,427,431).CCLS.	USPAT	OR	OFF	2005/07/19 14:17